## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

## Application of

Applicant : David L. Chapek

Serial No. : 09/605,293 Filed : June 28, 2000

Title : SEMICONDUCTOR DEVICES INCLUDING A LAYER OF

POLYCRYSTALLINE SILICON HAVING A SMOOTH

**MORPHOLOGY** 

Docket No. : MIO 0037 VA/40509.118 (96-0831.01)

Examiner : N. Drew Richards

Art Unit : 2815

Commissioner for Patents P.O. Box 1450

Alexandria, VA 22313-1450

EFS Web Electronic Submission November 7, 2007

## **AMENDMENT**

This Amendment is being filed in response to the Decision on Appeal decided September 21, 2007, in which new grounds of rejection were entered under 37 CFR §41.50(b). Applicants elect to reopen prosecution and are submitting an appropriate amendment of the rejected claims herewith. Reconsideration and reexamination of the application is respectfully solicited in light of the amendments and remarks below.